





Excimer laser mask imaging systems



Laser System XXL

| Specification | Unit | X-axis | Y-axis |
|------------------------|------|--------|--------|
| Travel | mm | 2000 | 1460 |
| Speed | mm/s | 200 | 360 |
| Resolution | nm | 20 | 20 |
| Repeatability | μm | ±2 | ±2 |
| Accuracy (full travel) | μm | ±4 | ±4 |



Additionally equipped with laser interferometer and temperature sensing to further enhance resolution and accuracy.

Laser System L

| Specification | Unit | XY-axis |
|------------------------|------|---------|
| Travel | mm | 400 |
| Resolution | nm | 40 |
| Repeatability | μm | ±0.2 |
| Accuracy (full travel) | μm | ±0.5 |

Laser Sources

| Specification | Unit | |
|-----------------|------|---------|
| Wavelength | nm | 248/193 |
| Average Power | W | 80/60 |
| Pulse Duration | ns | 20 |
| Beam Dimensions | mm | 10x24 |
| Beam Divergence | mrad | 1x3 |



Both systems in temperature controlled gray room facility

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Superlarge area processing of novel functional surfaces

Laser patterning of large surfaces opens cost-effective production of micro- and nano-structured master pieces in polymers. This technology, based on excimer laser ablation of polymers, is a key enabling technology for prototyping large scale micro- and nano-structured materials. It creates availability of technical otherwise difficult to produce structures for present and future industrial challenges. Within the large range of potential applications of these micro- and nano-structured surfaces, light management such as photon harvesting or the opposite that is tailored light distribution will be focused on. More demanding devices implying light guiding and light manipulation are further topics the laboratory will deal with.



High precision machining

Polymer Feature Geometry

- Optical resolution: ~ 1 μm
- Depth resolution: < 50 nm
- Wall angles and slopes: 0°–90°
- Highly engineered geometries
- High aspect ratio features
- Optical surface finish
- 100% fill factor





Processing materials for optical devices

Processable Materials:

- Polymers
- Metals
- Glasses
- Silicon
- Optical Materials
- Composites
- Ceramics
- Thin Films

Applications:

- Display
- Lighting
- Medical devices
- Photovoltaics
- Printed electronics
- Security markers



3D machining



Machining of many materials for specific applications

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